External_Type	Material_Group	Substances	CAS_Number	Mass	Mass_Percentage_in_Leaf	Massmg
Lead Frame	Copper alloy	Phosphorous (P)	7723-14-0	0.03722	0.1	0.401
	Copper alloy	Nickel (Ni) - cas no. 7440-02-0	7440-02-0	0.01117	0.03	0.1203
	Copper alloy	Iron (Fe)	7439-89-6	0.03722	0.1	0.401
	Copper alloy	Copper (Cu)	7440-50-8	37.13448	99.77	400.0777
			Subtotal	37.22009	100	401
Mould Compound	Polymer	Phenol Formaldehyde resin (generic)	9003-35-4	2.82019	4.8	30.384
	Polymer	Epichlorohydrin/Diethyleneglycol Epoxy resin (generic)	25928-94-3	5.87539	10.0	63.3
	Filler	Silica fused	60676-86-0	49.94082	85.0	538.05
	Carbon Black	Carbon black	1333-86-4	0.11751	0.2	1.266
			Subtotal	58.75391	100	633
Post-plating	Pure metal	Tin (Sn)	7440-31-5	2.32045	100.0	25
			Subtotal	2.32045	100	25
Die Attach	Lead alloy	Tin (Sn)	7440-31-5	0.01522	2.0	0.164
	Lead alloy	Silver (Ag)	7440-22-4	0.01903	2.5	0.205
	Lead alloy	Lead (Pb)	7439-92-1	0.72686	95.5	7.831
			Subtotal	0.76111	100	8.2
Wire	Pure metal	Aluminium (AI)	7429-90-5	0.02368	100.0	0.25513
			Subtotal	0.02368	100	0.25513
Die	Doped silicon	Silicon (Si)	7440-21-3	0.49194	100.0	5.3
			Subtotal	0.49194	100	5.3
Wire	Pure metal	Aluminium (Al)	7429-90-5	0.42882	100.0	4.62
			Subtotal	0.42882	100	4.62
			Total	100	100	1077.37513

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